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electrically connects to a source electrode S at the bottom surface of the semiconductor die 11. A P+ region 14 provides a conductive path to the N+ source region 12. A metal portion 18 shorts out a p+ body region 19 and the N+ source region 12 to provide an electrical path between the source region 12 to the source electrode S. A drain electrode D and a gate G are also at the top surface of the semiconductor die 11. For clarity of illustration, the gate oxide corresponding to the gate G is not shown in FIG. 1. The source electrode S at bottom surface of semiconductor die 11 is attached to a metallic substrate 13. The metallic substrate 13 serves as both a heat sink and a ground reference for the source electrode S. Wires (not shown) are coupled to the gate electrode G and the drain electrode D to provide the semiconductor die 11 with input and output connections. In operation, source current flows from the metallic substrate 13, laterally through the drift region 16 to the drain region 17, and out of the semiconductor die 11 to a wire (not shown) coupled to the drain electrode D.--

Please replace the paragraph at page 2, line 12 with the following paragraph:

--[08] One embodiment of the invention is directed to a semiconductor die package comprising: a semiconductor die comprising a vertical power transistor, wherein the semiconductor die has a first surface and a second surface; a source region at the first surface of the semiconductor die; a gate at the first surface of the semiconductor die; a drain region at the second surface of the semiconductor die; a ground plane proximate the second surface and distal to the first surface; and a bus member covering a portion of the first surface of the semiconductor die and having at least one leg, wherein the bus member electrically couples the source region of the semiconductor die to the ground plane.--

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Please replace the paragraph beginning at page 3, line 1 with the following paragraph:

semiconductor die package comprising: a semiconductor die comprising a vertical power transistor, wherein the semiconductor die has a first surface and a second surface; an emitter region at the first surface of the semiconductor die; a base region at the first surface of the semiconductor die; a collector region at the second surface of the semiconductor die; a ground plane proximate the second surface and distal to the first surface; and a bus member covering a portion of the first surface of the semiconductor die and having at least one leg, wherein the bus member electrically couples the emitter region of the semiconductor die to the ground plane.—

Please replace the paragraph beginning at page 3, line 9 with the following paragraph:

semiconductor die package comprising: a semiconductor die comprising a transistor, wherein the semiconductor die has a first surface and a second surface; a source region in the semiconductor die; a gate in the semiconductor die; a drain region in the semiconductor die; a ground plane proximate the second surface and distal to the first surface; and a bus member covering a portion of the first surface of the semiconductor die and having at least one leg, wherein the bus member electrically couples the source region of the semiconductor die to the ground plane.--

Please replace the paragraph beginning at page 3, line 27 with the following paragraph:

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--[16] FIG. 4 shows a top view of a portion of a semiconductor package according to an embodiment of the invention.--

Please replace the paragraph beginning at page 6, line 10 with the following paragraph:

have flat portions that form angles. For instance, the bus member 26 shown in FIG. 2 has a horizontal portion coupled to the source region 126 of the semiconductor die 30 and at least one leg that extends downward toward the ground plane 20. Preferably, the bus member 26 has two (or more) legs that extend to the ground plane 20 at opposite ends of the semiconductor die 30. The bus member 26 electrically couples the ground plane 20 to the source region 126. One leg is shown by the dotted lines in FIG. 2. In some embodiments, the horizontal portion of the bus member 26 can be a continuous body of metal and can cover a major portion of the first surface 31(a) of the semiconductor die 30 (e.g., greater than 50% of the area of the first surface 31(a)). Solder in the form of hemispherically shaped logs, balls, columns, etc. can be used to electrically couple the horizontal portion of the bus member 26 to various source region connections at the first surface 31(a) of the semiconductor die 30. Solder can also be used to couple the ends of the one or more legs of the bus member 26 to the ground plane 20.--

Please replace the paragraph beginning at page 7, line 12 with the following paragraph:

--[36] FIG. 4 shows a top plan view a portion a semiconductor die package with the inner leg surface of the bus member 26 shown by dotted lines. As shown in FIG. 4, the horizontal portion 26(a) can cover a majority of the upper surface of the semiconductor die 30. An area 30(b) of the semiconductor die 30 under the horizontal portion 26(a) of the bus member 26 can include source regions. An exposed